



前节内容回顾

❖ 1 封闭系统的热力学第一定律

$$\Delta U = Q + W$$

❖ 2 热力学基本关系式及微分关系

$$dU = TdS - pdV$$

$$dA = -SdT - pdV$$

$$dH = TdS + Vdp$$

$$dG = -SdT + Vdp$$

$$dZ = Mdx + Ndy \Rightarrow \left(\frac{\partial M}{\partial y} \right)_x = \left(\frac{\partial N}{\partial x} \right)_y$$

$$\left(\frac{\partial S}{\partial V} \right)_T = \left(\frac{\partial p}{\partial T} \right)_V \quad - \left(\frac{\partial S}{\partial p} \right)_T = \left(\frac{\partial V}{\partial T} \right)_p$$

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❖ 3 偏离函数

❖ 偏离函数是研究态相对于同温度的理想气体参考态的热力学函数的差值。

$$M - M_0^{ig} = M(T, p) - M^{ig}(T, p_0)$$

参考态是理想气体，与研究态同温度同组成，压力可相同也可以不同



应用：

$$\begin{aligned} & M(T_2, p_2) - M(T_1, p_1) \\ &= \left[M(T_2, p_2) - M^{ig}(T_2, p_0) \right] \\ & \quad - \left[M(T_1, p_1) - M^{ig}(T_1, p_0) \right] \\ & \quad + \left[M^{ig}(T_2, p_0) - M^{ig}(T_1, p_0) \right] \end{aligned}$$

**要求状态1和2具有相同的组成，并
取相同组成的参考态**



❖ § 3-5 T, p 为独立变量的偏离函数

❖ 在由状态方程模型推导

对于 $V=V(T, p)$ 形式的状

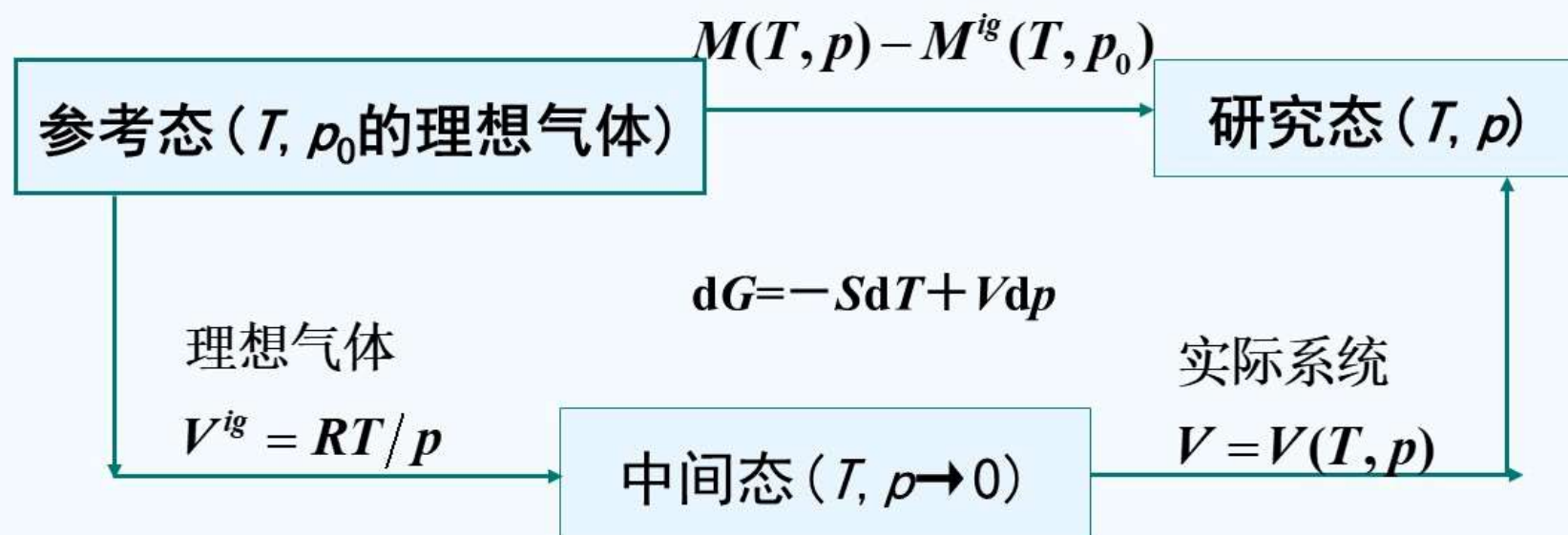
列的变化途径进行推导较为

$$dU = TdS - pdV$$

$$dH = TdS + Vdp$$

$$dA = -SdT - pdV$$

$$dG = -SdT + Vdp$$

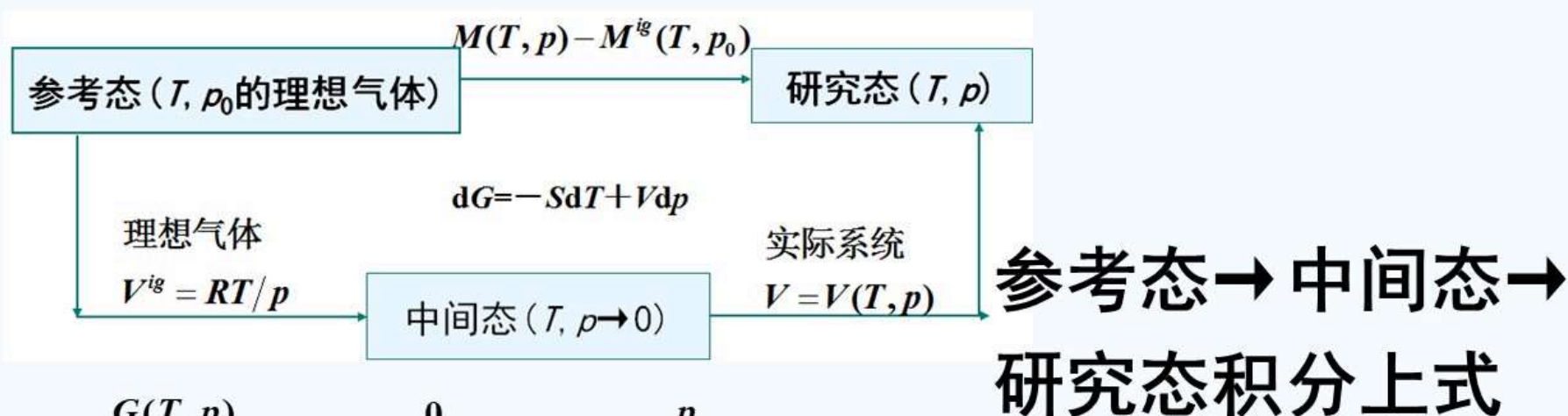


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❖ 1 偏离吉氏函数

❖ 已知 $dG = -SdT + Vdp$, 等温时, $[dG = Vdp]_T$



$$\int_{G^{ig}(T, p_0)}^{G(T, p)} dG = \int_{p_0}^0 V^{ig} dp + \int_0^p V dp$$

$$= \left[\int_{p_0}^0 V^{ig} dp + \int_0^p V^{ig} dp \right] + \left[\int_0^p V dp - \int_0^p V^{ig} dp \right]$$



$$\begin{aligned}
 &= \int_{p_0}^p V^{ig} dp + \int_0^p \left(V - V^{ig} \right) dp \\
 &= \int_{p_0}^p \frac{RT}{p} dp + \int_0^p \left(V - \frac{RT}{p} \right) dp \\
 &= RT \ln \frac{p}{p_0} + \int_0^p \left(V - \frac{RT}{p} \right) dp
 \end{aligned}$$

$V = V(T, p)$ 代入状态方程的具体形式积分计算



❖ 由此得偏离吉氏函数

$$G(T, p) - G^{ig}(T, p_0) = RT \ln \frac{p}{p_0} + \int_0^p \left(V - \frac{RT}{p} \right) dp$$

(3-37)

标准化处理后得

$$\frac{G - G_0^{ig}}{RT} - \ln \frac{p}{p_0} = \frac{1}{RT} \int_0^p \left(V - \frac{RT}{p} \right) dp$$

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❖ 2 偏离熵

由Maxwell关系式 $S = -\left(\frac{\partial G}{\partial T}\right)_p$ 得

$$S - S_0^{ig} = -\left[\frac{\partial(G - G_0^{ig})}{\partial T}\right]_p = -\left\{\frac{\partial\left[RT \ln \frac{p}{p_0} + \int_0^p \left(V - \frac{RT}{p}\right) dp\right]}{\partial T}\right\}_p$$

$$= -R \ln \frac{p}{p_0} + \int_0^p \left[\frac{R}{p} - \left(\frac{\partial V}{\partial T}\right)_p\right] dp$$

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❖ 标准化处理后得：

$$\frac{S - S_0^{ig}}{R} + \ln \frac{p}{p_0} = \frac{1}{R} \int_0^p \left[\frac{R}{p} - \left(\frac{\partial V}{\partial T} \right)_p \right] dp \quad (3-39)$$

✧ 3 其它偏离函数

✧ 由热力学基本关系式，经过数学推导
可得其它偏离函数



★ 1) 偏离焓

$$H = G + TS$$

$$H - H^{ig} = (G - G^{ig}) + T(S - S^{ig})$$

$$= \left[\cancel{RT \ln \frac{p}{p_0}} + \int_0^p \left(V - \frac{RT}{p} \right) dp \right] + T \left\{ \cancel{-R \ln \frac{p}{p_0}} + \int_0^p \left[\frac{R}{p} - \left(\frac{\partial V}{\partial T} \right)_p \right] dp \right\}$$

$$= \int_0^p \left[\cancel{V} - \cancel{\frac{RT}{p}} + \cancel{\frac{RT}{p}} - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp$$

$$\Rightarrow \frac{H - H^{ig}}{RT} = \frac{1}{RT} \int_0^p \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp$$

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✦ 2) 偏离热力学能

$$U = H - pV$$

$$U - U^{ig} = (H - H^{ig}) - p(V - V^{ig})$$

$$= \int_0^p \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp - pV + pV^{ig}$$

$$= \int_0^p \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp - ZRT + RT$$

$$\Rightarrow \frac{U - U^{ig}}{RT} = 1 - Z + \frac{1}{RT} \int_0^p \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp$$

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✦ 3) 偏离亥氏函数

$$A = U - TS$$

$$\frac{A - A_0^{ig}}{RT} - \ln \frac{p}{p_0} = 1 - Z + \frac{1}{RT} \int_0^p \left[V - \left(\frac{RT}{p} \right) \right] dp$$



✦ 4) 偏离等压热容

$$\left(\frac{\partial C_P}{\partial p}\right)_T = -T \left(\frac{\partial^2 V}{\partial T^2}\right)_p$$

$$\frac{C_P - C_p^{ig}}{R} = -\frac{T}{R} \int_0^p \left(\frac{\partial^2 V}{\partial T^2}\right)_p dp$$

✦ 以 T 、 p 为独立变量时，适合于以 V 为显函数的状态方程 $V = V(T, p)$ 来推导偏离函数



❖ 例 P40 3-2

偏离焓3-43
$$\frac{H - H^{ig}}{RT} = \frac{1}{RT} \int_0^p \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp$$

$$p(V - b) = RT + \frac{ap^2}{T} \Rightarrow V = \frac{RT}{p} + \frac{ap}{T} + b$$

$$V = \frac{RT}{p} + \frac{ap}{T} + b$$

$$\left(\frac{\partial V}{\partial T} \right)_p = \frac{R}{p} - \frac{ap}{T^2}$$



$$= \frac{1}{RT} \int_0^p \left[\left(\frac{RT}{p} + \frac{ap}{T} + b \right) - T \left(\frac{R}{p} - \frac{ap}{T^2} \right) \right] dp$$

$$= \frac{1}{RT} \int_0^p \left[\frac{2ap}{T} + b \right] dp$$

$$= \frac{1}{RT} \left(\frac{ap^2}{T} + bp \right) \Big|_0^p = \frac{1}{RT} \left(\frac{ap^2}{T} + bp \right)$$



偏离熵3-39

$$V = \frac{RT}{p} + \frac{ap}{T} + b$$

$$\left(\frac{\partial V}{\partial T}\right)_p = \frac{R}{p} - \frac{ap}{T^2}$$

$$\begin{aligned} \frac{S - S_0^{ig}}{R} + \ln \frac{p}{p_0} &= \frac{1}{R} \int_0^p \left[\frac{R}{p} - \left(\frac{\partial V}{\partial T}\right)_p \right] dp \\ &= \frac{1}{R} \int_0^p \left[\frac{R}{p} - \left(\frac{R}{p} - \frac{ap}{T^2} \right) \right] dp \\ &= \frac{1}{R} \int_0^p \frac{ap}{T^2} dp = \frac{ap^2}{2RT^2} \end{aligned}$$

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偏离摩尔定压热容3-46

$$\frac{C_P - C_p^{ig}}{R} = -\frac{T}{R} \int_0^p \left(\frac{\partial^2 V}{\partial T^2} \right)_p dp$$

$$= -\frac{T}{R} \int_0^p \frac{2ap}{T^3} dp$$

$$= -\frac{1}{R} \int_0^p \frac{2ap}{T^2} dp = -\frac{ap^2}{RT^2}$$

$$\Rightarrow C_P = C_p^{ig} - \frac{ap^2}{T^2} = c + \frac{d}{T} - \frac{ap^2}{T^2}$$

$$V = \frac{RT}{p} + \frac{ap}{T} + b$$

$$\left(\frac{\partial V}{\partial T} \right)_p = \frac{R}{p} - \frac{ap}{T^2}$$

$$\left(\frac{\partial^2 V}{\partial T^2} \right)_p = \frac{2ap}{T^3}$$

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$$H - H^{ig} = \frac{ap^2}{T} + bp \quad \int_{T_1}^{T_2} C_p^{ig} dT = \int_{T_1}^{T_2} \left(c + \frac{d}{T} \right) dT$$

❖ 计算状态1→2的焓变

$$\begin{aligned} H(T_2, p_2) - H(T_1, p_1) &= \left[H(T_2, p_2) - H^{ig}(T_2) \right] \\ &- \left[H(T_1, p_1) - H^{ig}(T_1) \right] + \left[H^{ig}(T_2) - H^{ig}(T_1) \right] \\ &= \left(\frac{ap_2^2}{T_2} + bp_2 \right) - \left(\frac{ap_1^2}{T_1} + bp_1 \right) + \int_{T_1}^{T_2} \left(c + \frac{d}{T} \right) dT \end{aligned}$$



$$= a \left(\frac{p_2^2}{T_2} - \frac{p_1^2}{T_1} \right) + b(p_2 - p_1) + c(T_2 - T_1) + d \ln \left(\frac{T_2}{T_1} \right)$$

❖ 假设： $a=2000\text{MPa}^{-1}\cdot\text{K}^{0.5}\cdot\text{cm}^3\cdot\text{mol}^{-1}$,
 $b=4\text{cm}^3\cdot\text{mol}^{-1}$, $c=9\text{MPa}\cdot\text{K}^{-1}\cdot\text{cm}^3\cdot\text{mol}^{-1}$,
 $d=0.2\text{MPa}\cdot\text{cm}^3\cdot\text{mol}^{-1}$, $p_1=0.5\text{MPa}$, $T_1=298\text{K}$,
 $p_2=2\text{MPa}$, $T_2=373\text{K}$, 状态1→2的焓变值=?

$$\Delta H = a \left(\frac{p_2^2}{T_2} - \frac{p_1^2}{T_1} \right) + b(p_2 - p_1) + c(T_2 - T_1) + d \ln \left(\frac{T_2}{T_1} \right)$$



✦ 同理 $S(T_2, p_2) - S(T_1, p_1) = [S(T_2, p_2) - S^{ig}(T_2, p_2)]$
 $- [S(T_1, p_1) - S^{ig}(T_1, p_1)] + [S^{ig}(T_2, p_2) - S^{ig}(T_1, p_1)]$

$$S - S^{ig} = \frac{ap^2}{2T^2} \quad \int_{T_1}^{T_2} \left(\frac{C_p^{ig}}{T} \right) dT - R \ln \frac{p_2}{p_1}$$

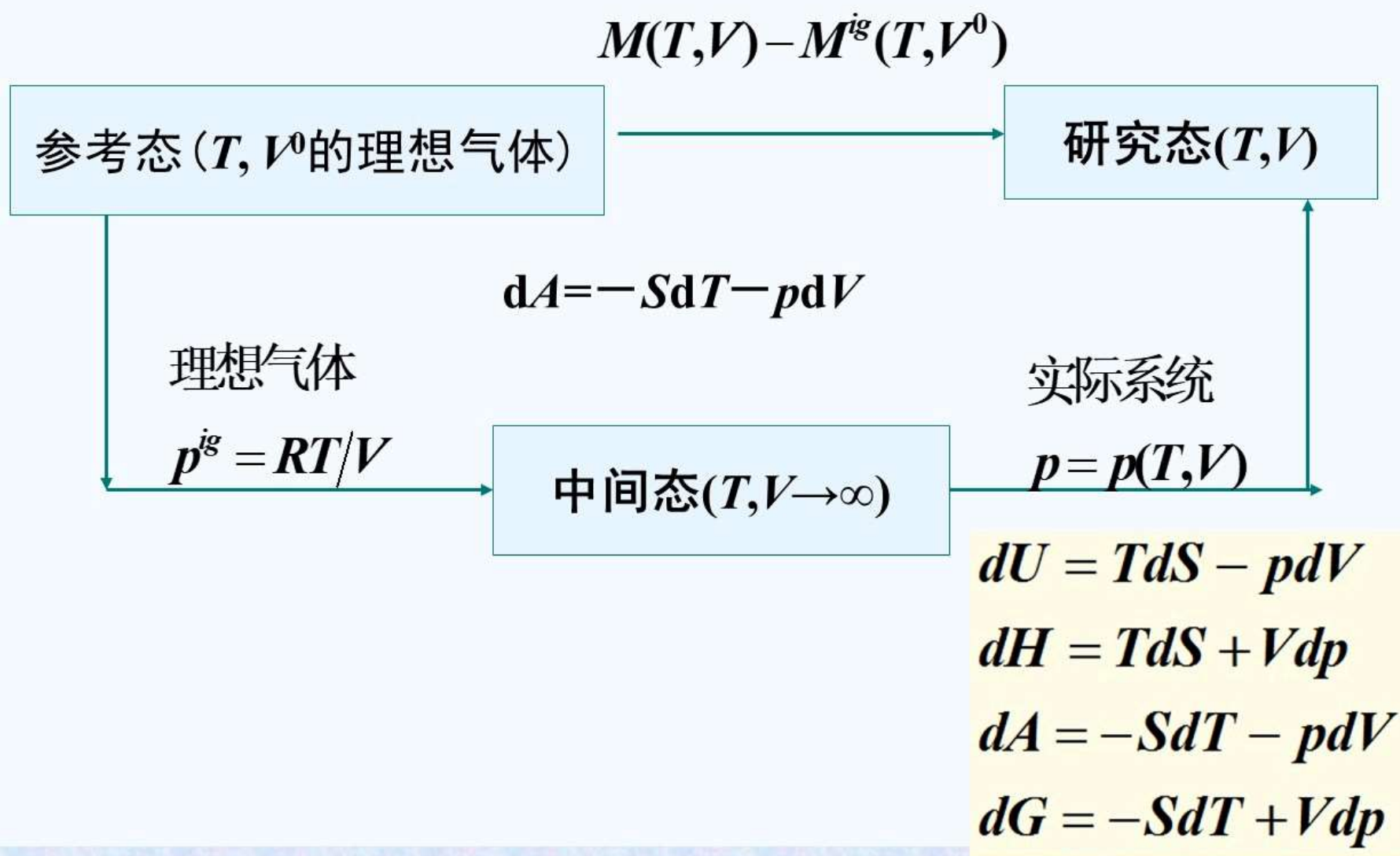
$$= \frac{ap_2^2}{2T_2^2} - \frac{ap_1^2}{2T_1^2} + \int_{T_1}^{T_2} \left(\frac{c + \frac{d}{T}}{T} \right) dT - R \ln \frac{p_2}{p_1}$$

$$= \frac{a}{2} \left(\frac{p_2^2}{T_2^2} - \frac{p_1^2}{T_1^2} \right) + c \ln \left(\frac{T_2}{T_1} \right) - d \left(\frac{1}{T_2} - \frac{1}{T_1} \right) - R \ln \frac{p_2}{p_1}$$

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- ❖ § 3-6 T, V 为独立变量的偏离函数
- ❖ 工程上用得更多地 $p-V-T$ 关系是以 p 为显函数的 $p=p(T, V)$ 形式的状态方程, 这时, 以 T, V 为独立变量使用起来更方便。
- ❖ 推导的变化途径如图





✦ 1 偏离亥氏函数

- ❖ 由基本关系式 $dA = -SdT - pdV$ ，可得等温条件下 $[dA = -pdV]_T$
- ❖ 按照所设计的变化途径积分得，

$$\begin{aligned} A(T, V) - A^{ig}(T, V_0) &= \int_{V_0}^{\infty} -p^{ig} dV + \int_{\infty}^V -pdV \\ &= -\int_{V_0}^{\infty} \frac{RT}{V} dV - \int_{\infty}^V pdV \end{aligned}$$



$$\begin{aligned}
 &= \left[-\int_{V_0}^{\infty} \frac{RT}{V} dV - \int_{\infty}^V \frac{RT}{V} dV \right] - \left[\int_{\infty}^V p dV - \int_{\infty}^V \frac{RT}{V} dV \right] \\
 &= - \left[\int_{V_0}^V \frac{RT}{V} dV \right] - \left[\int_{\infty}^V \left(p - \frac{RT}{V} \right) dV \right] \\
 &= -RT \ln \frac{V}{V_0} + \left[\int_{\infty}^V \left(\frac{RT}{V} - p \right) dV \right]
 \end{aligned}$$

$p = p(T, V)$ 代入状态方程的具体形式积分计算



❖ 即偏离亥氏函数为

$$A - A_0^{ig} = -RT \ln \frac{V}{V_0} + \left[\int_{\infty}^V \left(\frac{RT}{V} - p \right) dV \right]$$

$$\text{由于 } \frac{V}{V_0} = \frac{ZRT/p}{RT/p_0} = Z \left(\frac{p_0}{p} \right)$$

所以又有

$$A - A_0^{ig} = -RT \ln Z + RT \ln \frac{p}{p_0} + \left[\int_{\infty}^V \left(\frac{RT}{V} - p \right) dV \right]$$

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✦ 标准化处理后得

$$\frac{A - A_0^{ig}}{RT} - \ln \frac{p}{p_0} = -\ln Z + \frac{1}{RT} \int_{\infty}^V \left(\frac{RT}{V} - p \right) dV \quad (3-51)$$

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❖ 2 偏离熵

$$\text{由 } S = -\left(\frac{\partial A}{\partial T}\right)_V$$

$$S - S_0^{ig} = -\left[\frac{\partial(A - A_0^{ig})}{\partial T}\right]_V$$

$$= -\left\{\frac{\partial\left[-RT \ln \frac{V}{V_0} + \int_{\infty}^V \left(\frac{RT}{V} - p\right) dV\right]}{\partial T}\right\}_V$$

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$$= R \ln \frac{V}{V_0} + \int_{\infty}^V \left[\left(\frac{\partial p}{\partial T} \right)_V - \frac{R}{V} \right] dV$$

$$= R \ln Z - R \ln \frac{p}{p_0} + \int_{\infty}^V \left[\left(\frac{\partial p}{\partial T} \right)_V - \frac{R}{V} \right] dV$$

✦ 标准化处理后得

$$\frac{S - S_0^{ig}}{R} + \ln \frac{p}{p_0} = \ln Z + \frac{1}{R} \int_{\infty}^V \left[\left(\frac{\partial p}{\partial T} \right)_V - \frac{R}{V} \right] dV$$

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✧ 3 其它偏离函数

✧ 由定义式及热力学基本关系式，经过数学推导可得其它偏离函数

✧ 1) 偏离热力学能

✧ $U = A + TS$

$$\frac{U - U_0^{ig}}{RT} = \frac{1}{RT} \int_{\infty}^V \left[T \left(\frac{\partial p}{\partial T} \right)_V - p \right] dV$$



✧ 2) 偏离焓

$$\star H = U + pV$$

$$\frac{H - H_0^{ig}}{RT} = Z - 1 + \frac{1}{RT} \int_{\infty}^V \left[T \left(\frac{\partial p}{\partial T} \right)_V - p \right] dV$$

❖ 3) 偏离吉氏函数

$$\star G = H - TS = A + pV$$

$$\frac{G - G_0^{ig}}{RT} - \ln \frac{p}{p_0} = Z - 1 - \ln Z + \frac{1}{RT} \int_{\infty}^V \left(\frac{RT}{V} - p \right) dV$$



❖ 4) 偏离等容热容

$$\frac{C_V - C_V^{ig}}{R} = \frac{T}{R} \int_{\infty}^V \left(\frac{\partial^2 p}{\partial T^2} \right)_V dV$$

✦ 5) 偏离等压热容

$$\frac{C_p - C_p^{ig}}{R} = \frac{T}{R} \int_{\infty}^V \left(\frac{\partial^2 p}{\partial T^2} \right)_V dV - \frac{T}{R} \frac{(\partial p / \partial T)_V^2}{(\partial p / \partial V)_T} - 1$$

以 T 、 V 为独立变量的 $C_p(T, V)$ 的偏离函数在工程上应用较多。

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❖ 例： 气体符合van der Waals (vdW) 方程，
导出偏离亥氏函数、偏离焓、偏离熵、偏离
等容热容

$$p = \frac{RT}{V-b} - \frac{a}{V^2}$$

$$\left(\frac{\partial p}{\partial T} \right)_V = \frac{R}{(V-b)}$$

$$\left(\frac{\partial^2 p}{\partial T^2} \right)_V = 0$$



❖ 偏离亥氏函数

$$\begin{aligned}
 \frac{A - A_0^{ig}}{RT} - \ln \frac{p}{p_0} &= -\ln Z + \frac{1}{RT} \int_{\infty}^V \left(\frac{RT}{V} - p \right) dV \\
 &= -\ln Z + \frac{1}{RT} \int_{\infty}^V \left[\frac{RT}{V} - \left(\frac{RT}{V-b} - \frac{a}{V^2} \right) \right] dV \\
 &= -\ln Z + \int_{\infty}^V \left(\frac{1}{V} - \frac{1}{V-b} \right) dV + \frac{1}{RT} \int_{\infty}^V \frac{a}{V^2} dV \\
 &= -\ln Z + \ln \frac{V}{V-b} - \frac{a}{RTV}
 \end{aligned}$$

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偏离熵

$$\begin{aligned}\frac{S - S_0^{ig}}{R} + \ln \frac{p}{p_0} &= \ln Z + \frac{1}{R} \int_{\infty}^V \left[\left(\frac{\partial p}{\partial T} \right)_V - \frac{R}{V} \right] dV \\ &= \ln Z + \frac{1}{R} \int_{\infty}^V \left[\frac{R}{(V-b)} - \frac{R}{V} \right] dV \\ &= \ln Z + \ln \frac{V-b}{V}\end{aligned}$$



偏离焓

$$\begin{aligned}\frac{H - H_0^{ig}}{RT} &= Z - 1 + \frac{1}{RT} \int_{\infty}^V \left[T \left(\frac{\partial p}{\partial T} \right)_V - p \right] dV \\ &= Z - 1 + \frac{1}{RT} \int_{\infty}^V \left[T \frac{R}{V-b} - \left(\frac{RT}{V-b} - \frac{a}{V^2} \right) \right] dV \\ &= Z - 1 + \frac{1}{RT} \int_{\infty}^V \frac{a}{V^2} dV = Z - 1 - \frac{a}{RTV}\end{aligned}$$

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偏离等容热容

$$\frac{C_V - C_V^{ig}}{R} = \frac{T}{R} \int_{\infty}^V \left(\frac{\partial^2 p}{\partial T^2} \right)_V dV$$
$$= 0$$

❖ 常用状态方程的偏离焓、偏离熵、偏离定压热容见 P47表3-1



❖ 练习3.3:

- ❖ 1 某流体符合状态方程 $p(V-b)=RT$ ，写出以 T, p 为独立变量的状态方程，以 T, V 为独立变量的状态方程。
- ❖ 2 某流体符合状态方程 $p(V-b)=RT$ ，推导其偏离焓、偏离熵与 $p-V-T$ 的关系（以 T, p 为独立变量；以 T, V 为独立变量）



以T,p为独立变量的计算为例

$$p(V - b) = RT \quad V = \frac{RT}{p} + b$$

$$\left(\frac{\partial V}{\partial T} \right)_p = \frac{R}{p}$$

$$H - H^{ig} = \int_0^P \left[V - T \left(\frac{\partial V}{\partial T} \right)_p \right] dp = \int_0^P \left[\frac{RT}{p} + b - T \frac{R}{p} \right] dp = bp$$

$$S - S_0^{ig} + R \ln \frac{p}{p_0} = \int_0^P \left[\frac{R}{p} - \left(\frac{\partial V}{\partial T} \right)_p \right] dp = \int_0^P \left[\frac{R}{p} - \frac{R}{p} \right] dp = 0$$

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以T,V为独立变量计算为例

$$\begin{aligned}\frac{H - H_0^{ig}}{RT} &= Z - 1 + \frac{1}{RT} \int_{\infty}^V \left[T \left(\frac{\partial p}{\partial T} \right)_V - p \right] dV \\ &= Z - 1 + \frac{1}{RT} \int_{\infty}^V \left[T \left(\frac{R}{V-b} \right) - p \right] dV \\ &= Z - 1 = \frac{pV}{RT} - 1 = \frac{b}{V-b}\end{aligned}$$

$$p(V-b) = RT$$

$$p = \frac{RT}{V-b}$$

$$\left(\frac{\partial p}{\partial T} \right)_V = \frac{R}{V-b}$$

$$\begin{aligned}\frac{S - S_0^{ig}}{R} + \ln \frac{p}{p_0} &= \ln Z + \frac{1}{R} \int_{\infty}^V \left[\left(\frac{\partial p}{\partial T} \right)_V - \frac{R}{V} \right] dV \\ &= \ln Z + \frac{1}{R} \int_{\infty}^V \left[\frac{R}{(V-b)} - \frac{R}{V} \right] dV \\ &= \ln Z + \ln \frac{V-b}{V} = \ln \frac{pV}{RT} \cdot \frac{V-b}{V} = \ln 1 = 0\end{aligned}$$

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